

U.S. Patent Application Serial No. 10/807,174  
Amendment filed March 28, 2007  
Reply to OA dated November 28, 2006

**AMENDMENTS TO THE CLAIMS:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims:**

**Claim 1 (Currently Amended):** A composition comprising:

a siloxane resin prepared by heating a mixture containing tetraalkoxysilane, an alkyltrialkoxysilane, and/or a trialkoxysilane, as well as a solvent, followed by vaporizing a predetermined amount of alcohol which is not a polymetallosiloxane;

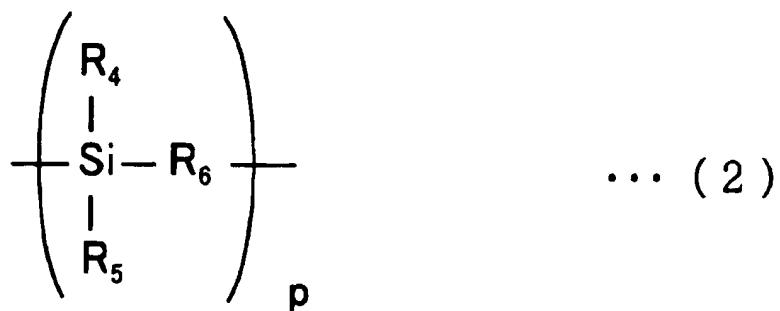
a silicon compound substantially consisting of silicon, carbon and hydrogen, wherein the number ratio of carbon forming an -X- bond (wherein X is (C)<sub>m</sub> (where m is an integer in the range of from 1 to 2 or 3), or a substituted or unsubstituted aromatic group with 9 or less carbon atoms) to silicon atoms in the main chain of one molecule is in the range of from 2:1 to 12:1;

a dissipating agent for forming pores, said dissipating agent comprising a substance that loses its weight by 5% by weight or more at 150°C and by 90% by weight or more at 400°C when heated up at a rate of 10°C/min from usual temperature; and

the balance being a solvent.

U.S. Patent Application Serial No. 10/807,174  
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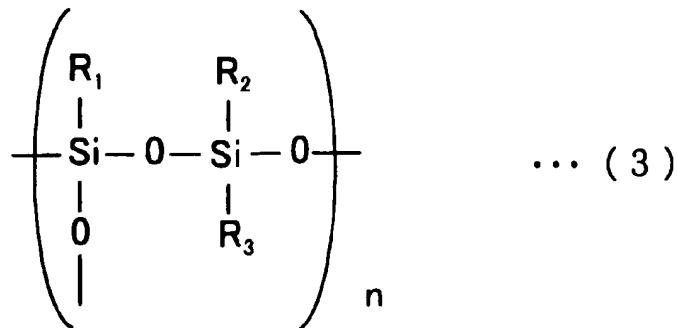
**Claim 2 (Original):** A composition according to claim 1, wherein said silicon compound has a structure represented by formula (2):



(wherein  $R_4$  and  $R_5$  are each, same or different, H, an aliphatic hydrocarbon group with 1 to 3 carbon atoms, or a substituted or unsubstituted aromatic hydrocarbon group with 6 to 9 carbon atoms;  $R_6$  is an aliphatic hydrocarbon group with 1 to 3 carbon atoms, or a substituted or unsubstituted phenylene group; and  $p$  is an integer in the range of from 20 to 1,000).

U.S. Patent Application Serial No. 10/807,174  
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**Claim 3 (Original):** A composition according to claim 1, wherein said siloxane resin has a structure represented by formula (3):



(wherein R<sub>1</sub>, R<sub>2</sub>, and R<sub>3</sub> are each, same or different, hydrogen, fluorine, a methyl group or an -O- group; and n is an integer in the range of from 5 to 1,000).

**Claim 4 (Original):** A composition according to claim 1, wherein said siloxane resin is obtained:

by subjecting to a heat treatment a mixture containing a tetraalkoxysilane (a) and an alkyltrialkoxysilane and/or trialkoxysilane (b) at a molar ratio (a:b) of 0:1 to 1:0; and

U.S. Patent Application Serial No. 10/807,174  
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by releasing from 100 to 400 moles of alcohols out of 100 moles of (a + b), the total of the tetraalkoxysilane (a) and the alkyltrialkoxysilane and/or trialkoxysilane (b).

**Claim 5 (Original):** A composition according to claim 1, wherein the carbon concentration in said siloxane resin is in the range of from 1 to 80 atom% based on the total atoms of the siloxane resin.

**Claim 6 (Original):** A composition according to claim 1, wherein the concentration of hydrogen atoms directly bonded to silicon in said siloxane resin is in the range of from 1 to 25 atom% based on the total atoms of the siloxane resin.

**Claim 7 (Original):** A composition according to claim 1, wherein from 0.1 to 200 parts by weight of said silicon resin is used based on 100 parts by weight of said siloxane resin.